MACK T-12 "X" TOP RING ANALYSIS

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Mack T-12 New Top Ring Batch

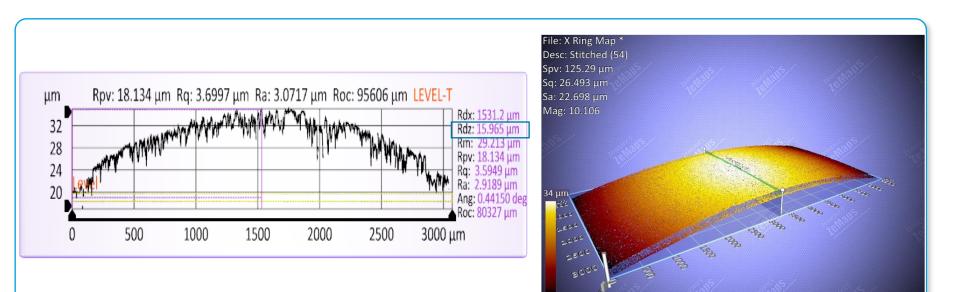


- Recently a new batch of top rings was introduced into the Mack T-12 and is currently undergoing reference testing at the labs
- The new top ring batch that was introduced was the "X" batch
- Infineum has conducted analysis of this "X" top ring batch and has compared it to data of previous top ring batches that was previously shared with the Surveillance Panel

Rings used in this analysis

- "N" used top ring
- "P" used top ring
- "S" new top ring
- "T" new top ring
- "U" new top ring
- "X" new top ring

Top Ring Barrel Rise



Top Ring Batch	Barrel Rise (μm)
S	24.7 – 25.8
Т	11.1 – 14.9
U	13.5 – 14.8
Х	12.1 – 16.0

-61 µm



Top Ring Coating Elemental Analysis

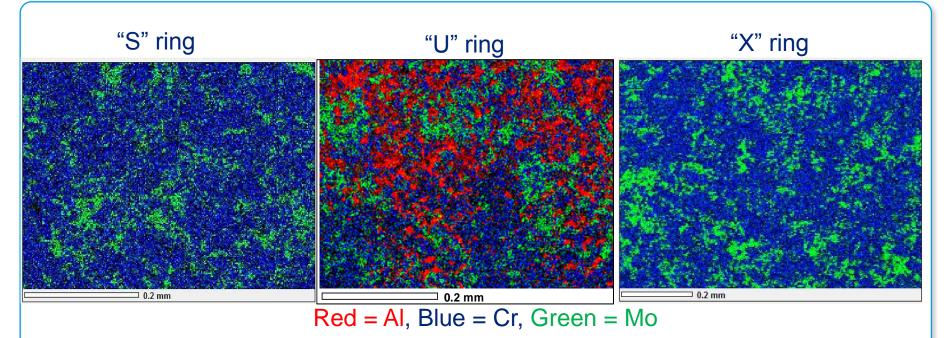


Element	"N" Ring Mole %	"P" Ring Mole %	"S" Ring Mole %	"T" Ring Seg 1 Mole %	"T" Ring Seg 2 Mole %	"U" Ring Seg 1 Mole %	"X" Ring Seg 1 Mole %	"X" Ring Seg 2 Mole %	"X" Ring Seg 3 Mole %
Cr	40.92	29.54	41.42	30.68	25.59	19.09	37.93	38.38	36.53
Мо	1.60	1.92	1.88	2.01	1.67	1.46	1.99	1.9	1.96
Ni	8.91	10.13	7.99	8.73	6.64	5.05	7.77	7.6	7.44
AI	0.62	1.20	0.25	0.54	6.88	16.91	0.13	0.15	0.16
С	41.43	42.09	42.39	48.22	46.48	48.81	47.24	47.19	48.59
0	4.51	11.18	5.18	7.50	10.05	7.65	4.56	4.4	4.91
Si	0.18	1.06	0.55	0.77	0.60	0.79	0.3	0.37	0.41
Zn	0.40	0.48	0.35	0.59	0.38	0.25	0.08	0	0

• New "X" batch similar to "S" batch. Ni and Mo domains are consistent in both batches.

Top Ring Coating Elemental Analysis

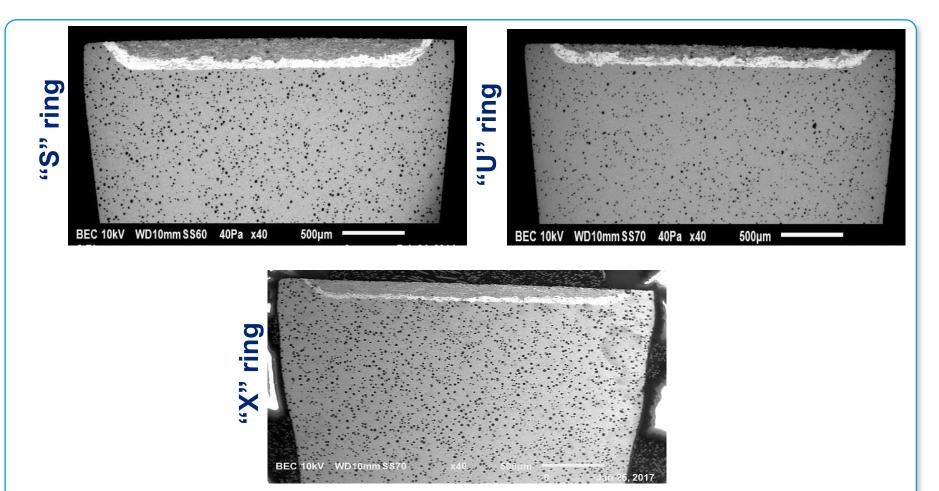




- Surface Aluminum added in the "U" batch ring is no longer present in the "X" batch ring.
- Mo/Ni-rich domains are present in the coating structure of the "X" batch ring similar to "S" batch.

Cross Section Analysis of Rings

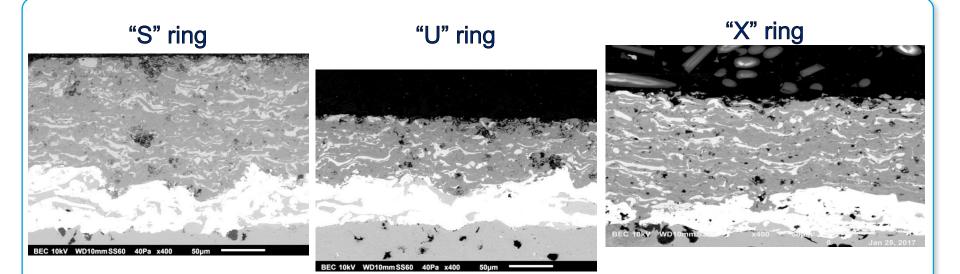




- Coating bulk structure seems to be similar in all 3 batches
- Substrate material is ductile iron and similar for all 3 batches

Cross Section Analysis of Rings



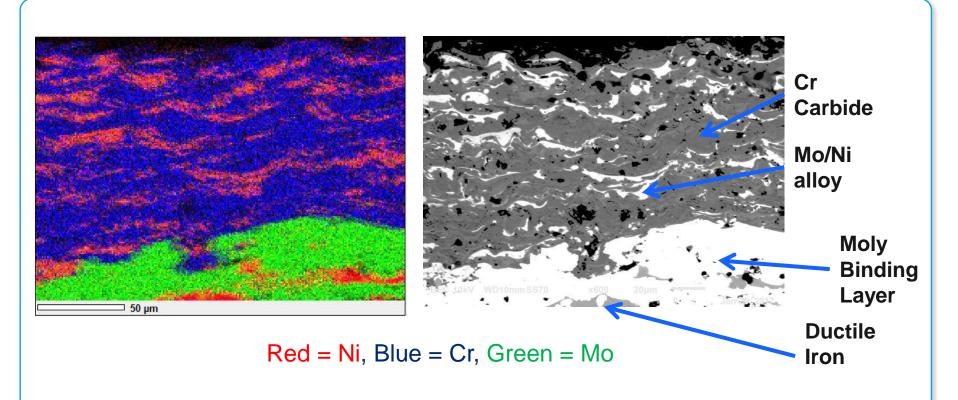


Ring Batch	Coating Thickness (μm) Including Mo Layer
S	200
U	127
Х	161

- Mo/Ni alloy domains are evenly distributed close to the surface as seen in previous "S" and "U" batches.
- Mo binding layer present between ductile iron substrate and coating
- "X" ring coating has a thickness in between the "S" and "U" batches

Cross Section Analysis X-ring

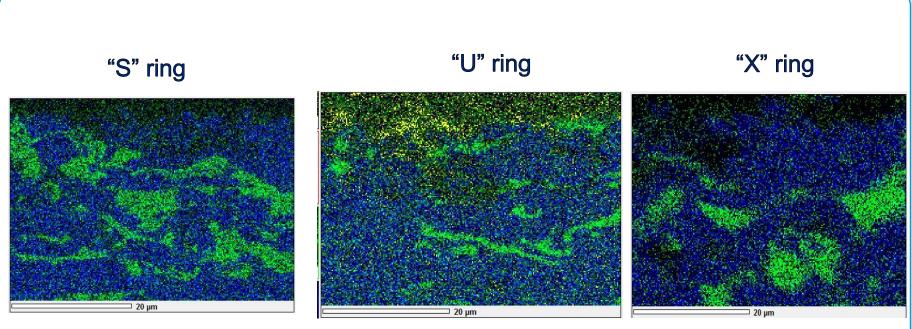




- Coating contains Ni/Mo domains that can be found at surface and in substructure.
- "X" ring has a substantial surface and bulk pore structure

Cross Section Analysis of Rings



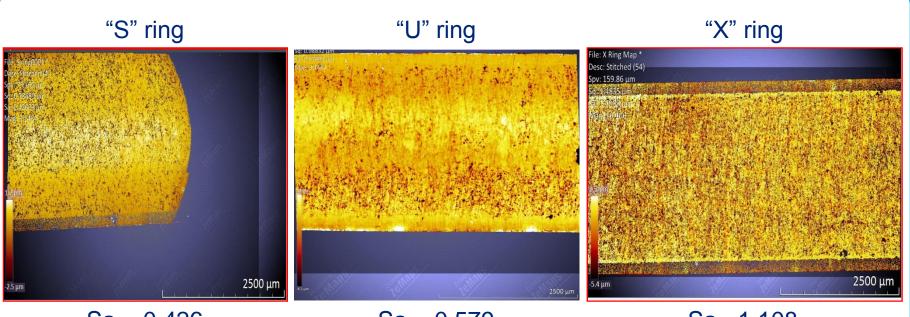


Blue = Cr, Green = Mo, Yellow=Al

- Surface aluminum particles found in "U" batch rings are not present in "S" or "X" batch.
- Cross-section of "X" batch indicates similarity to "S" batch.

Top Ring Pore Density





Sa = 0.426

Sa = 0.579

Sa =1.108

- Surface of "X" batch ring has a higher amount of pores compared to previous ring batches
- Surface roughness of "X" batch rings is also higher than previous batches
- "U" batch ring had pores more concentrated to lower half of ring
- "X" batch pore distribution is uniform as previously seen in "S" batch.

Molybdenum Domain Uniformity X-ring



File: X Ring Map * Molybdenum domains Desc: Stitched (54) ٠ Spv: 159.86 µm are uniform in size Sq: 1.5236 μm throughout coating 1.1452 µm 10,106 surface, similar to "S" batch. Blue = CrGreen = Mo2500 um -5.6 µm 0.2 mm 0.2 mm 0.2 mm

Ring Side Coating Elemental Analysis



Element	"T" Ring Mole %	"U" Ring Mole %	"X" Ring Mole %
Ρ	9.64	9.9	5.32
Fe	8.3	13.67	4.19
С	32.6	24.91	61.65
0	35.38	36.84	25.04
Si	0.54	0.73	0.39
Zn	12.3	13.96	0
Mn	0	0	3.41
Ca	1.24	0	0

"T" and "U" batch rings have a Zinc Phosphate coating on the sides and back
"X" batch rings have a Manganese Phosphate coating on the sides and back

Conclusion



- The barrel rise and symmetry is similar to the previous couple of batches of rings.
- The structure of the ring coating has changed between batches.
 - Coating elemental composition is similar between "X" and "S" batch rings.
 - Aluminum surface domains present in previous batches of rings ("T" & "U") have been removed to match earlier ring batches.
 - Coating thickness has been increased from the "U" to "X" batch in the direction of earlier ring batches.
 - Surface pore distribution is uniform in both "X" and "S" batch rings.
 - Concentrated pore distribution to lower half of "U" batch rings has been removed
 - Roughness of "X" batch rings and pore concentration has increased compared to previous batches of rings.
- Corrosion protection layer on side and back of ring has changed composition from "T"/"U" batch ring to the "X" batch ring.



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